

DOCKET NO: 247866US2S



IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
AKIRA HOKAZONO, ET AL. : EXAMINER: LOKE, S. H.
SERIAL NO: 10/759,205 :
RCE FILED: DECEMBER 29, 2005 : GROUP ART UNIT: 2811
FOR: SEMICONDUCTOR DEVICE :
HAVING METAL SILICIDE FILMS
FORMED ON SOURCE AND
DRAIN REGIONS AND METHOD
FOR MANUFACTURING THE
SAME

AMENDMENT UNDER 37 C.F.R. § 1.111

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated February 23, 2006, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 8 of this paper.